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Temperature Influence on pH-ISFET sensor operating in Weak and Moderate Inversion Regime: Model and circuitry

S. E. Naimi, B. Hajji, I. Humenyuk, J. Launay, P. Temple-Boyer

Abstract

Usually most pH-ISFET readout circuits, with temperature compensation, were designed using transistors operating in strong regime. However, a classes of circuits elaborated with respect to MOS weak inversion are also very suitable for low-voltage and low-power applications. In this work, we discuss the problem of temperature variation at the sensor and circuit level. An analysis was made of the sensor operating in weak and moderate inversion regime. It has been shown that a simplified version of the EKV model combined with site-binding model can describe the behavior of ISFET toward the temperature and pH change. The experimental results agree very well with the analytical model for devices in large intervals of pH and temperature. Finally, the usage of model development is considered with an original concept of a readout circuit. The result of the simulation shows that the output signal is linear with pH, the design technique permits improving temperature insensitivity. The proposed circuit can be integrated with an ISFET by standard CMOS technology.

Keywords: pH-ISFET, EKV-model, Weak inversion, Thermal drift, Readout circuit

1. Introduction

Since its development in the 1970 [1], the Ion-Sensitive field effect transistors (ISFET) has been receiving more attention especially in areas of environmental monitoring applications and biomedical analysis. As a result, it has been used for the detection of multiple ions due to its many ion-sensitive membranes [2, 3]. However, many industrial and laboratory applications require the precise measurements of pH. Commercially available sensors are generally very expensive devices, especially if reasonable precision and reliability are requested. Several investigations have demonstrated that the pH-ISFET sensor presents some drawbacks related to thermal dependency and long-term drift [4–6]. These factors limit the performances of pH-ISFET sensors, leading to unacceptable results in critical measurements. In order to improve the pH-ISFETs stability, a lot of temperature compensation techniques have been reported in the literature such as the proper choice of biasing current for isothermal operating point to reduce ISFET temperature coefficient, the use of a p-n junction diode for temperature compensation on a single ISFET device, an ISFET based operational amplifier employment that improves temperature stability or the combination of several methods [7–9]. At the same time a lot of work has been done in the last thirty years, including simulations of its temperature characteristics according to theoretical models. They show that the ISFET temperature dependence is complicated in nature. Generally, these models were based on the so-called site-binding model and the MOSFET theory. The temperature influence is relatively complicated since it’s related to the reference electrode, electrolyte/insulator potential and ISFET based MOS transistors [10]. Additionally, the ISFET sensor is used, classically, in his strong inversion regime, this implies high power consumption, while the trend towards low-voltage operation, both for reasons of compatibility with digital technology, and to meet the needs of battery-operated equipment. Another strategy is to consider the weak-inversion operating. Previous studies have shown this possibility [11]. Sub-threshold MOS operation, or weak inversion, is most often required by the low-power applications in modern electronics.

This article reviews our recent successful modeling of the temperature influence on pH-ISFET sensors by using MOSFET theory and site-binding model. In this work we implemented a simplified Enz-Krummenacher-Vittoz (EKV) model to explain the characteristics of ISFET sensor [12], in weak and moderate inversion regime, and discuss how the temperature can affect the behavior of the sensor. This paper deals with temperature-dependent ISFET drift modeling development and to its validation by comparison with experimental measurements. We have, also, investigated an alternative circuit operating in a sub-threshold regime to have a linear relation between an output and the pH, and an improved thermal stability of this output.

2. ISFET electrical properties: background review

2.1. pH sensitive film/electrolyte interface modeling

Figure 1 shows a simplified schematic representation of the pH-ISFET sensor using p-type silicon substrates. The basic
structure that serves as the basis for the ISFET is fabricated in standard CMOS chip technology. In the following and based on already existing theories, we combined the well-known site binding model and the MOSFET model to describe the behavior of an ISFET sensor. In many devices of this kind, it is assumed that protons interact with the insulator according to site-binding theory. Whereas in the case of silicon nitride membrane, several studies have demonstrated that when the Si$\text{N}_2$ surface is exposed to water, a sensitive surface becomes oxygen rich [13]. Consequently the silicon nitride surface contains sites in two forms, silanedi (SiOH) and amine groups (SiNH$_2$), previous works have mentioned that all other sites can be neglected. More details on the site-binding theory can be found in [14–16]. A first-order model simplification suggests that if the electrolyte concentration is reasonable, the hypothesis of mono-sites is plausible. With this simplification the response of the sensor to the pH is given by the surface potential $\psi_0$ and dependent on the pH value of the electrolyte, it can be expressed as:

$$\psi_0 = 2.303 \frac{KT}{q} \frac{\beta_0}{1 + \beta_0} (pH_{\text{pcc}} - pH)$$  \hspace{1cm} (1)

where $T$ is the temperature of the system, $K$ is the Boltzmann’s constant, $q$ the electron charge, $pH_{\text{pcc}}$ is the non zero pH, and $\beta_0$ is a parameter which reflects the chemical sensitivity of the gate insulator and is dependent on the density of surface sites $N_s$ and the double layer capacitance $C_{DL}$. The parameter $\beta_0$ is given by:

$$\beta_0(T) = \frac{2q^2N_s \sqrt{K_a.K_b}}{KTC_{DL}}$$  \hspace{1cm} (2)

where $K_a$, $K_b$ are dissociation constants for the chemical reactions at the insulator interface. The double layer capacitance $C_{DL}$ consists of the two series capacitances $C_{\text{Gouy}}$ and $C_{\text{Helm}}$, where $C_{\text{Gouy}}$ represent the equivalent Gouy-Chapman capacitance and $C_{\text{Helm}}$ the Helmholtz capacitance, which has already been developed by site-binding theory and the electrical double-layer theory [17, 18]. It should be noted that $C_{\text{Gouy}}$ and $C_{\text{Helm}}$ are temperature dependent, however, since these are second-order effects, we will assume $C_{\text{Gouy}}$ and $C_{\text{Helm}}$ to be independent of temperature [5].

Thus, it has been possible to investigate the pH-ISFET flat-band voltage shift with pH and the variation of the potential at the electrolyte/gate dielectric interface. In summary, the flat-band voltage shift has a standard expression:

$$\Delta V_{FB} = V_{pH} = E_{\text{ref}} + \chi^{\text{sol}} + \Delta \psi_0 - \psi_0$$  \hspace{1cm} (3)

where $E_{\text{ref}}$ is the potential of Ag/AgCl reference electrode, $\Delta \psi_0$ is the potential drop between the reference electrode and the solution, which typically has a value of 3mV, $\chi^{\text{sol}}$ is the electrolyte-insulator surface dipole potential, with a typical value of 50mV [10]. Both $\Delta \psi_0$ and $\chi^{\text{sol}}$ are pH independent. $\psi_0$ is the surface potential from (1). In equation (3), $\psi_0$ is the only parameter responsible for ISFET pH sensitivity, as previously explained by the site binding theory. Hence the macro-model represented schematically in Fig.2.

2.2. MOSFET part modeling : EKV Model

The working principle of the ISFET is based on the standard MOSFET structure. Therefore, a robust model, of the MOSFET part, is suitable for performing robust and valid model in a large interval of temperatures and pH. Another critical point might be the number of parameters for each model, who must be smallest. EKV model is particularly suitable as it provides accurate modeling with a small set of parameters [12]. This section describes the equations and parameters used for the computer simulation version of the EKV-MOSFET model. The set of equations includes modeling of basic physical effects, geometrical aspect, substrate effect, modeling of mobility reduction due to vertical field and modeling of thermal behavior. The EKV model proposes the following empirical expression of source-drain current ($I_{DS}$) valid for all regimes of operating:

$$I_{DS} = 2n\beta U_T^2 [ln^2(1 + e^{-\frac{V_{GS}-V_{pH}}{2E_{\text{ff}}}}) - ln^2(1 + e^{-\frac{V_{GS}-V_{pH}}{2E_{\text{ff}}}})]$$  \hspace{1cm} (4)

where $U_T$ is the thermodynamic voltage, $V_{TO}$ is the threshold voltage, $n$ is the body effect factor and $\beta$ the transfer parameter, $V_{GS}$ is the gate to source voltage, $V_{DS}$ is the source potential and $V_D$ is the drain potential. For long channel model implementation, we consider only parameters accounting for first order effects. The model used is based on the ideal MOS structure of long and large channel with uniform substrate doping. Notice that the current expression in (4) is let as a difference between forward and reverse current using standard interpolation function, thus a better fitting is obtained in weak and moderate inversion. The expressions of EKV parameters $V_{TO}$, $n$ and $\beta$ are:
3. ISFET Temperature characteristic

We consider two of the parameters for intrinsic model $\gamma$, $\phi_f$ and $K_p$ are related to process parameters like oxide thickness and channel doping. Generally it is preferable to avoid to link such parameters for better fitting of experimental measurements.

3.2. Temperature coefficient of the reference electrode

The liquid solution, which acts as the gate ion-conductor, is connected to the gate voltage source by means of an Ag/AgCl reference electrode. The potential of the reference electrode $E_{ref}$ is related to the temperature according to the expression [10]:

$$E_{ref}(T) = E_{abs}(H^+/H_2) + E_{ref}(Ag/AgCl) 
+ \left( \frac{dE_{ref}}{dT} \right)(T - 298.16)$$

Where $E_{abs}(H^+/H_2)$ is the normalized hydrogen potential, $E_{ref}(Ag/AgCl)$ is the relative potential of the reference electrode, the two potential are temperature independent (their values are respectively 4.7V and 0.205V), the temperature coefficient of AgCl/Solution junction is practically negligible, $d(E_{ref})/dT$ is the temperature coefficient equal to 140μV/K [21-23].
5. The readout circuit

Since the purpose of this work is to study the benefit of using an ISFET sensor in weak-inversion regime, we propose a simple readout IC with low temperature dependence. From (4) it can be easily shown that the source-drain current $I_{DS}$, in weak inversion region, must comply with the following requirement ($V_S = 0$, $V_{DS} \gg V_T$):

$$I_{DS} = 2n\beta U_T^2 e^{-\frac{V_{GS}-V_{TH}}{nU_T}}$$  \hspace{1cm} (14)

With $V_{ph} = \Delta V_{FB}$, thus the macro-model of the ISFET in Fig. 2 is still available in weak inversion. This section explores some ideas on how to use such results in a simple circuit.

5.1. Basic principle of the circuit

For $V_{ph}$ we get from equations (1)(3) and (13):

$$V_{ph} = 2.303U_T(pH - pH_{ref}) + E_{ref}(\frac{A_g}{A_{AgCl}})$$

$$+ (\frac{dE_{ref}}{dT})(T - 298) + \chi^\text{sol} + \Delta \phi)$$

The absolute potential of the standard hydrogen electrode $E_{abs}(\frac{pH}{T})$ is compensated by the work function of the metal back contact/electronic charge [18]. Let us consider the expression in (15), it can be rewritten as:

$$V_{ph} = V_1 - V_2 = a_{ph}U_T + b$$

With

$$\begin{align*}
a_{ph} &= 2.303(pH - pH_{ref}) + q \frac{dE_{ref}}{dT} \\
b &= E_{ref}(\frac{A_g}{A_{AgCl}}) - 298.16 \frac{dE_{ref}}{dT} + \chi^\text{sol} + \Delta \phi)
\end{align*}$$  \hspace{1cm} (17)

These two terms, $a_{ph}$ and $b$, being to the first approximation independent of the temperature. The temperature-dependency of the first term of $V_{ph}$ ($a_{ph}U_T$) can be eliminated if the pH-ISFET is operating in weak inversion. The problem, however, will still not be solved; the resulting term $b/U_T$ cannot be eliminated easily (as by a differential structure). In the following analysis, we focus on this second term and try to minimize its influence. In equation (16), $V_{ph}$ is expressed as a differential potential $(V_1 - V_2)$, if each potential passes through an attenuator circuit, the output of the attenuator stage is $(V_3 - V_4)$, with:

$$V_3 - V_4 = a_1V_1 - a_2V_2$$

yielding

$$\frac{V_3 - V_4}{U_T} = \frac{a_1V_1 - a_2(V_1 - b)}{U_T} + a_2a_{ph}$$  \hspace{1cm} (19)

If $a_1$ and $a_2$ are chosen as $a_1V_1 \approx a_2(V_1 - b)$, the expression in equation 19 becomes:

$$\frac{V_3 - V_4}{U_T} = a_2a_{ph} = a_2(2.303(pH - pH_{ref}) + q \frac{dE_{ref}}{dT})$$

(20)

The last expression in equation (20) is a function of pH but temperature independent (we suppose that the effect of the temperature on $pH_{ref}$ and $dE_{ref}/dT$ is negligible). However, the
term $\alpha_2$ must be temperature independent. To achieve the earlier condition, $\alpha_1 V_1 = \alpha_2 (V_1 - b)$, the potential $V_1$ does not have to vary too much. In the next subsections we propose a circuit able to extract the potential $V_{ph}$ and then divide it by the thermal potential $U_T$. This illustrates the general principle of the proposed circuit. The basic topology of this circuit is given in Fig. 3, it has three stages as shown in the figure. As suggested previously, once the tension $V_{ph}$ is extracted (with the first stage), the two components of a differential potential are passed through two attenuators in the second stage, the third stage allows to divide the output by a thermal voltage $U_T$. In the previous considerations, the voltage $V_1$, can obviously be fixed by a reference voltage, placed in the gate of the transistor M13. However, this tension is used actually to keep for each stage, the tension resulting from the sensor as a differential voltage. This will allow a better linearization of the output.

5.2. First stage : modified Caprio’s Quad

The first stage of the circuit in Fig. 3 is based on a Caprio’s Quad, which is originally a V-I converter. The circuit is useful for moderate input amplitudes, the voltage swing at the input cannot be very large (±500mV at most). The equivalent voltage source $V_{ph}$ is accurately replicated across the source connections of M3 and M4. The current sources $I_1$ allow limiting the currents in a desired region (sub-threshold or moderate inversion regions). Obviously the pH-ISFET and the transistor M2 should have a perfectly matched ration $W/L$. As previously mentioned, the potential $V_1$ must be constant or variable in reasonable limits, this can be achieved by adjusting the width of the transistor M4. Consequently the greatest variation of the voltage $V_1$ was found to be around 6% for large variations of the temperature and the pH ($T = 20 – 60 °C, \text{pH} = 2 – 12$). Thus, the voltage swing, $V_2 - V_1$ is caused by the variation of $V_2$. In the next section we will discuss this results.

5.3. Second stage : attenuators

The output of each attenuator (M5, M6, M7, M8 or M9, M10, M11, M12) is linearly proportional to inputs. One of these attenuators can be used to have $\alpha_1 V_1 = \alpha_2 (V_1 - b)$ as mentioned previously. In fact we need this stage to reduce the potentials values for the entry of the third stage too. It is assumed that good layout techniques will help reduce errors due to process and thermal variations. These circuits are very immune to temperature for great variations of the entry.

5.4. Third stage : source coupled circuit

A differential amplifier composed of the two matched transistors M13 and M14 in addition to the source current $I_2$, provides a simple method of realizing a division of the input voltage by the thermal potential $U_T$. The basic equation of the circuit is:

$$I_{out} = I_{DM13} - I_{DM14} = I_2 \times \tanh \left( \frac{V_d}{2\eta U_T} \right)$$

(21)

where $I_{DM13}$, $I_{DM14}$ are the drains current of M13 and M14, $V_d$ is the differential input voltage ($V_d = V_s - V_i$) and $\eta$ is the sub-threshold slope factor. Equation (21) assumes that M13 and M14 are operating in weak inversion. If the circuit operates under the restriction, $|V_d| << U_T$, the output current of the circuit is given by:

$$I_{out} \approx I_2 \frac{V_d}{2\eta U_T}$$

(22)

The circuit uses the current mirror as an active load (M15-M16). Note that the output of the circuit is a current, and if it is required to have an output voltage, a differential current to voltage converter is needed. To simplify this can be realized by using a resistor ($R$) as shown, in this case, the output voltage is given by:

$$V_{out} \approx R I_2 \frac{V_d}{4\eta U_T}$$

(23)

As the differential-pair (M13-M14) does not operate correctly for large signal. Therefore we are constrained to make the Caprio’s quad signals pass through two attenuator circuits to reduce the input voltages. In order to demonstrate the feasibility of the proposed circuit and to show an improvement of the temperature independent output, we simulate this circuit by using the MOSIS CMOS (AMI 1.0µm) minimum channel length technology and SPICE parameters. The electronic circuit simulation program HSPICE, which is one of the simulators that can be suitably adapted to design and simulate the ISFET transducers has been used.

6. Simulation results and discussion

6.1. ISFET characteristics

The equations provided in the previous sections are used to simulate the ISFET behavior under different operating conditions. The EKV parameters and site-binding coefficients are determined from experimental data. In order to obtain an optimized set of coefficients, it is desirable to take into account all types of experimental data, e.g. temperature, pH and gate-source voltage ($Vgs$) changes. The parameters are determined from the experimental data by an efficient mathematical, least squares minimization, methods.

Drain to source current versus gate to source voltage ($Ids - Vgs$) curves, measured in buffer solutions of different pH, are shown in Fig. 4-5-6. We present the results as a series of plots. The curves are shifted by 54.7mV/pH at 23°C to a positive voltage for the samples immersed in higher-pH buffer solutions, which can be explained by the site binding theory. The experimental results were found to be in agreement with the theoretical predictions. As can be seen from Fig. 7, the fitted curves accurately match the measured values at pH 4, 10 and specific value of pH 7 (Fig.9-b). In a second experiment, the pH-ISFET was operating in a buffer solution at pH 5.2 with temperature varied in from 10 to 52°C. Taking into account that the model is relatively simple, the simulation results are satisfactory. The fit is excellent, for all ranges of pH and temperature in weak inversion and remain good for moderate inversion. Obviously, for long and wide device we would expect the best agreement, with a few MOSFET part parameters.
Table 1: Extracted model parameters for MOSFET part and surface potential parameters values with regression statistics for a total of 23 tested devices. ($N_A$ is the substrate p-type doping concentration, $RF$ is the Reliability Factor ($RF$ was calculated for each device), (*) no temperature variations were made for this process).

The model parameters (EKV and site binding) were obtained through a nonlinear regression process, by the least squares method. The mean value, as well as the standard deviation of each parameter are given in Table 1. Data processing was done for 23 devices tested under various pH and temperature conditions. As we used a nonlinear regression, the reliability factor ($RF$) defined in equation 24 is used to measure of the goodness of fit instead of the coefficient of determination ($R^2$). In equation 24, $Ids_{exp}(i)$ is the experimental measurement number i, while $Ids_{th}(i)$ is the calculated values.

$$Reliability\ Factor = \sqrt{\frac{\sum_{i=1}^{n} (Ids_{exp}(i) - Ids_{th}(i))^2}{\sum_{i=1}^{n} (Ids_{exp}(i))^2}} \quad (24)$$

6.2. Temporal drift and hysteresis experiments

Drift phenomena in pH-ISFETs typically appear as relatively slow, monotonic, and temporal changes in the threshold voltage of the device. Figure 8 shows the gate to source ($Vgs$) voltage drift when $Ids$ and $Vds$ were fixed to 100$\mu$A and 1V respectively, while the buffer solution is at pH 10. The test was made for approximately 4h. A heating/cooling cycle has been performed to estimate the influence of the temperature on the pH-ISFET. The experiment of the illumination influence has been performed in the same test (by switching on the light, the room illumination is at pH 10. The test was made from 70 to 1500 Lux).

The shift of $\Delta Vgs$ is around 5mV (equivalent to 0.1 pH measurement error). Firstly, the pH-ISFETs responses are characterized by a decrease which should be related to their adaptation to the watery medium. The increase of temperature from 22°C to 40°C is responsible for an increase of the output voltage around 25mV. This phenomenon is related to the decrease of the ISFET threshold voltage. The initial period being apart, the complete experiment has also allowed estimating the temporal drift of the pH-ISFETs around 7.5mV/hour, i.e. 0.15pH/hour. When the heating/cooling cycle is no longer, the temporal drift is still evidenced but is strongly reduced. The drift can be estimated to 1mV/hour, i.e. 0.02pH/hour. Like the time drift effect, the hysteresis also limits the accuracy of ISFET pH measurements. Hysteresis tests were performed by varying the pH.
to close a loop (4 - 7 - 10 ↔ 10 - 4 - 7). All tested devices exhibit hysteresis of approximately 8-10mV, in sub-threshold region. Figure 9 depicts the hysteresis curves measured under the pH loop at $T = 22\,^\circ C$ and $I_{ds} = 20\mu A$.

All series of measurements have been devoted to characterizing the static sensor response, i.e. the dependence of the source-drain current versus source-grid tension on the pH and temperature changes in weak and moderate inversion regime. Based on these results, the behavioural thermal drift of the pH-ISFET in the sub-threshold region can be modeled by a combination of basic EKV model for the MOSFET part of the ISFET and a simplistic version of the site-binding model using Martinoa macro-model [25] presented in Fig. 2. On the other hand, the electrolyte-membrane part plays an important role in the static characteristics of the sensors. The thermal effect of the electrode/electrolyte/membrane cannot be neglected and limiting the performance of the sensor ($E_{ref}$ drift is around 0.14mV/$^\circ C$), the threshold voltage thermal drift of the MOS part is around 9mV/$^\circ C$ and the surface potential drift is around 1mV/$^\circ C$.

6.3. Circuit simulation

Figure 10 shows the temperature and the pH actions on the first stage outputs ($V_1$ and $V_2$). As can be seen from the figure, the pH influences significantly the potential $V_2$ instead of the potential $V_1$. The maximal variation of $V_1$ can be estimated around 19mV (6%), while that of $V_2$ is approximately 410mV, for pH varying from 2 to 12. As an analytical calculation of the attenuation $a_1$ ($a_2$) is very difficult (especially to take into account of the effect of the temperature variation). The influence of the temperature, the canal width of the transistor M10 and the pH on the terms $a_1 V_1$, $a_2 (V_1 - b)$ and $a_1 V_1 - a_2 (V_1 - b)$ was simulated. The results of these simulations are shown in figure 11. The circuit displayed a minimum change of the term $a_1 V_1 - a_2 (V_1 - b)$ under several conditions such as the change of temperature or the potential $V_1$. In figure 11 the change of the potential $V_1$ is imposed by the variation of the pH from 1 to 12, the potential $V_1$ was extracted from the simulation of the...
As illustrated by figure 12, the circuit simulation shows a linear response across a large range of pH, as well as a very insensitive temperature behavior. We show that this compact circuit provides accurate response, although the temperature varies between 20 and 60°C. The thermal compensation scheme provides an improved thermal stability by eliminating the temperature effect on the circuit output. The width of the transistor M4 of the Caprio’s-quad was adjusted to keep the potential \( V_1 \) constant. The simulation results confirm the theoretical considerations presented in the paper. The circuit output presents a maximum voltage drift, with temperature, around 28\( \mu \)V/°C for \( pH=12 \) and 3.7\( \mu \)V/°C for \( pH=5 \). The maximum power consumption of the readout circuit was estimated to be around 18.6mW. In integrated IC application perspective, the power supply and the biasing currents can be further minimized by reducing the aspect ratios of ISFET device and all transistors for lowering the total power consumption.

### 7. Conclusions

In this study, we analyzed the behavior of a pH-ISFET sensor shown by changing the temperature and the pH of the electrolyte solution. The simulation results show that the combination of a simplified EKV model with basic description of a surface potential can fit experimental results with good accuracy in weak and moderate regimes.

The model takes into account a temperature dependency of reference electrode, the \( SiO_2/Si_3N_4 \) electrolyte/insulator inter-
face and the semiconductor part of the pH-ISFET. The model was able to explain the experimental measurements of threshold voltage drift, estimated around 9mV/C (at T=300K). The extracted value of $pH_{rec}$ (4.2 at T=300K) is in good agreement with the reported values for $Si_3N_4$ ion sensitive membrane. The temporal drift combined to the thermal drift shows the limits of the pH sensors, the drift was estimated to 0.02 pH. If the thermal hysteresis is performed, this value increases to 0.15 pH for a shift of approximately 20°C. The study introduces, also, an original architecture that implements a low-power readout circuit for a pH-ISFET featuring thermal compensation, based on MOS transistors operated in sub-threshold. The ISFET thermal model is used to simulate a proposed readout circuit. As a result, the circuit output voltage drift, with temperature, is less than 3.7μV/°C, around pH=5. The main advantage of the proposed solution consists in the absence of a temperature sensor, resulting in a greater simplicity of the circuit.

References


Biographies

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